Form PTO 1449 (Modified)	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE			ATTY DOCKET NO. 295727US0PCT	SERIAL NO. 10/594,282			
				APPLICANT				
LIST OF	REFE	RENCES CITED BY AP	PLICANT	Hirotoshi ISHII, et al.				
				FILING DATE		GROUP		
				September 26, 2006	1752			
				U.S. PATENT DOCUMENTS			-	
EXAMINER		DOCUMENT			1	SUB		FILING DATE
INITIAL		NUMBER	DATE	NAME	CLASS	CLASS		
	AA					**		
	AB							
	AC							
	AD		Ţ				-	
	AE		<u> </u>					
-	AF							
	AG							
	AH							
-	AI							
	AJ						-	
	AK							
	AL							
	AM							
	AN							
, <u></u>		<u></u>	F01	DEIGN DATENT DOCUMENTO				
		ı	FUI	REIGN PATENT DOCUMENTS				
		DOCUMENT NUMBER	DATE	COUNTRY		TRANS YES		SLATION NO
	AO							
	AP							
	AQ							
	AR							
	AS							
	ΑТ							
	AU							
	AV							
, -		OTHER RE	FERENCES (I	ncluding Author, Title, Date, Pertine	nt Pages, et	c.)		
	AW	Osamu HABA, et al., "A New Photoresist Based on Calix [4] resorcinarene Dendrimer", CHEMISTRY OF MATERIALS, VOI 11, No. 2, XP-002470141, 1999, pages 427-432						
	АХ							
	AY							
	AZ				T			
Examiner					Additional References sheet(s) attached			
*Examiner: Ini	tial if re	eference is considered.	whether or not	citation is in conformance with MPEP 6	Date Considered 609; Draw line through citation if not in			
conformance a	and no	t considered. Include co	py of this form	with next communication to applicant.				